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APPLICATION NUMBER	FILING or 371(c) DATE	GRP ART UNIT	FIL FEE REC'D	ATTY.DOCKET.NO	TOT CLAIMS	IND CLAIMS
10/580,469	05/25/2006	1633	550	0076964-000024	13	4

**CONFIRMATION NO. 1471**

21839  
BUCHANAN, INGERSOLL & ROONEY PC  
POST OFFICE BOX 1404  
ALEXANDRIA, VA 22313-1404

**CORRECTED FILING RECEIPT**



\*OC000000038502222\*

Date Mailed: 10/30/2009

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please submit a written request for a Filing Receipt Correction. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections

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**Assignment For Published Patent Application**

REXGENEBIOTECH CO., LTD., Chungcheongbuk-do, KOREA, REPUBLIC OF

**Power of Attorney:** The patent practitioners associated with Customer Number 21839

**Domestic Priority data as claimed by applicant**

This application is a 371 of PCT/KR04/00251 02/09/2004

**Foreign Applications**

REPUBLIC OF KOREA 10-2003-0084329 11/26/2003

**If Required, Foreign Filing License Granted:** 01/06/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US 10/580,469**

**Projected Publication Date:** Not Applicable

**Non-Publication Request:** No

**Early Publication Request:** No

**\*\* SMALL ENTITY \*\***

**Title**

Composition for preventing and treating climacteric symptoms comprising the extract of sophorae fructus

**Preliminary Class**

435

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